

Supplementary information

Improved Efficiency of Large Area Cu(In,Ga)Se₂ Solar Cell by Non-toxic Hydrogen-Assisted Solid Se Vapor Selenization Process

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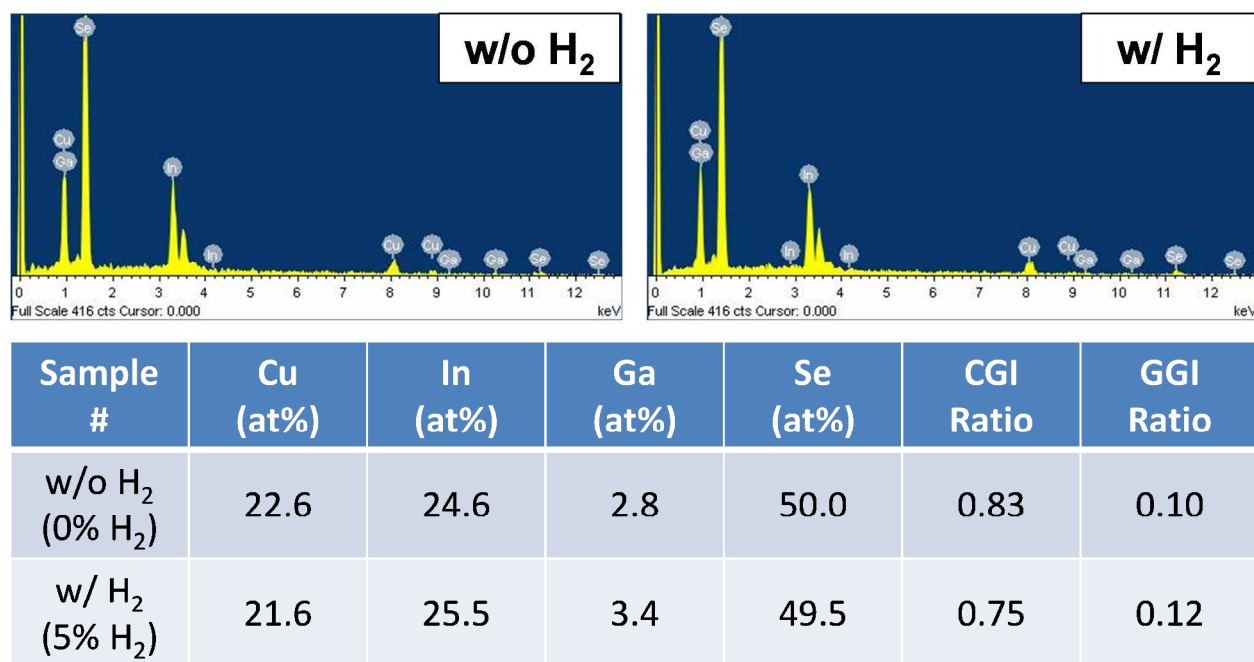


Figure S1 EDS quantitative results for CIGS thin films after the non-toxic hydrogen-assisted Se vapor selenization process and the selenization in the N₂ ambeint. Both samples exhibit the identical stoichiometric atomic composition ratio of bulk volume [Cu/(In+Ga)~0.8, Se~50 %].

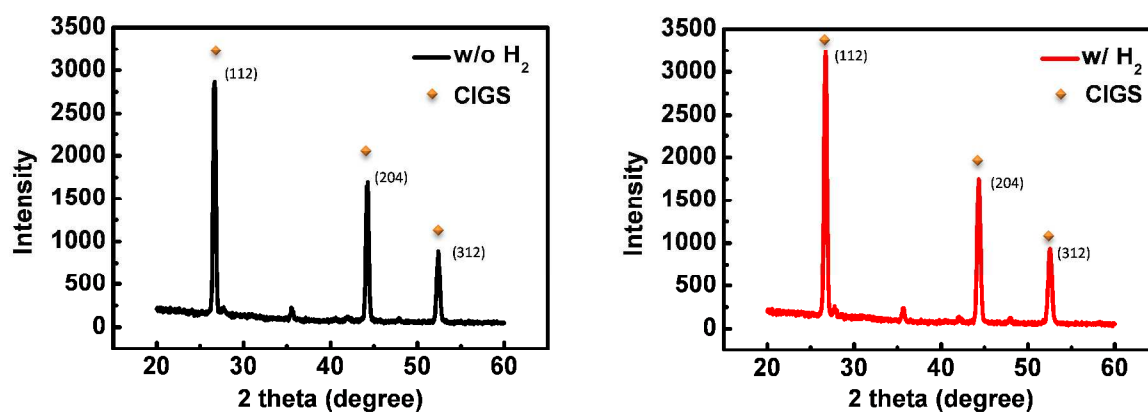
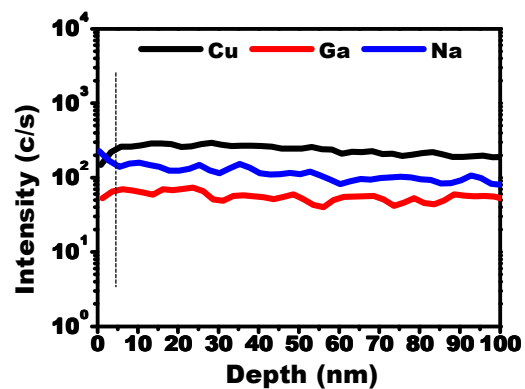
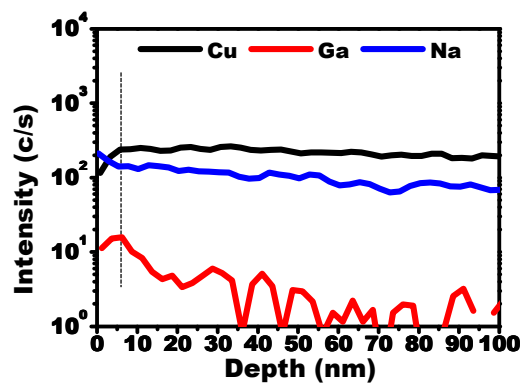


Figure S2 X-ray sspectra for CIGS thin films after the non-toxic hydrogen-assisted Se vapor selenization process and the selenization in the N₂ ambeint. Btoth samples exhibit good crystallinity and strong (112) and (220)/(204) preferred orientation from GIXRD results.

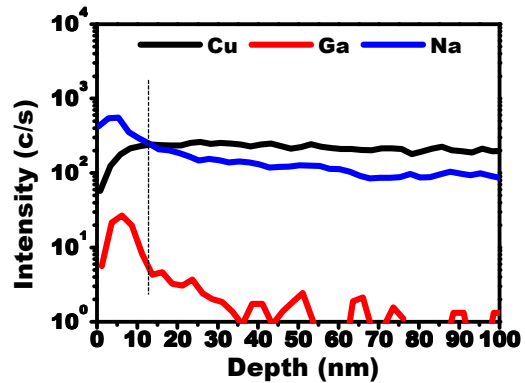
(a) 0% H₂ (CIGS surface)



(b) 5% H₂ (CIGS surface)



(c) 15% H₂ (CIGS surface)



(d) 25% H₂ (CIGS surface)

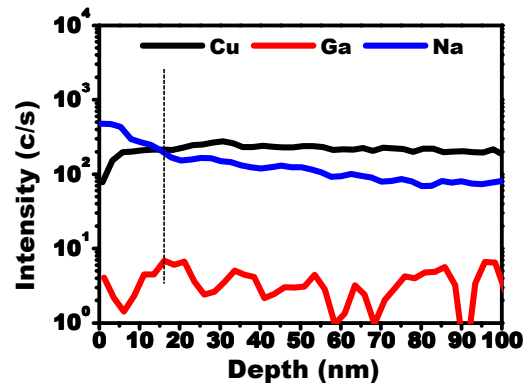


Figure S3 Near surface SIMS depth profiles of CIGS surface for (a) pure N₂ ambient (0% H₂), (b) 5 % H₂, (c) 15 % H₂, and (d) 25% H₂, respectively.

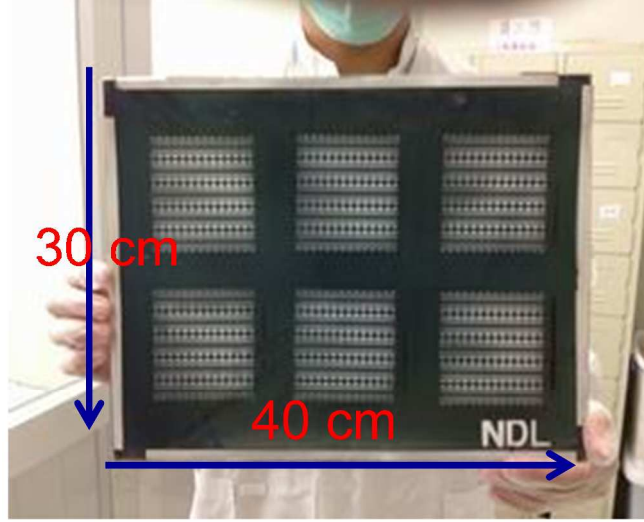


Figure S4 CIGS solar cell panels (30 cm× 40 cm)

Emitting Mechanisms

Radiative processes of CIGS thin films may include band-impurity (BI) and donor-to-acceptor (DAP) transitions. The emission spectra of these three peaks are fitted by BI (CB to A1), DAP1 (D1 to A1), and DAP2 (D1 to A2) recombination models. The extracted donor level and acceptor level are consistent with shallow A1- mostly Cu vacancy (V_{Cu}), shallow D1 – mostly Se vacancy (V_{Se}), and deep A2 – mostly O occupied Se vacancy (O_{Se}) at the energies of ($E_v + 0.03$ eV), ($E_c - 0.08$ eV) and ($E_v + 0.12$ eV), respectively^{1,2}. I_{BI} and I_{DAP1} are relative intensities of BI and DAP1 transitions where I_{DAP1} / I_{BI} positively relative to intensity of PL mapping. The ratios increase with H_2 ratios represent less existence of deep level defects.

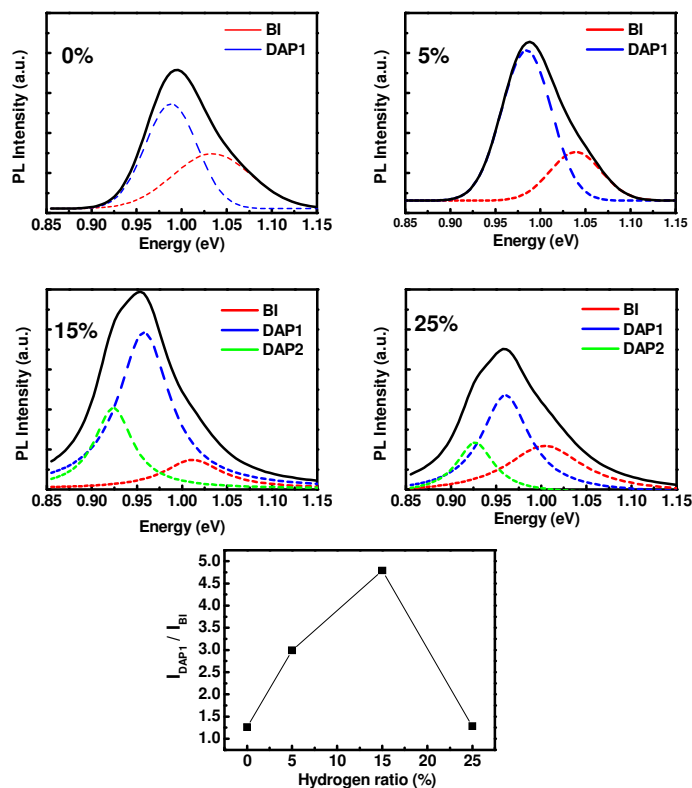


Figure S5 Low temperature PL of I_{DAP1} to I_{BI} relative ratio corresponds to PL mapping intensity.

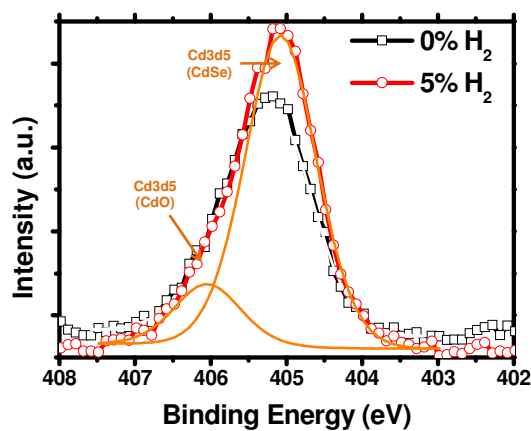


Figure S6 XPS bonding characterization of samples with and without hydrogen-assisted Se vapor selenization. The Cd-Se bonding intensity increases in hydrogen assisted selenization sample, which is due to wider copper poor region lead to more cadmium ions diffuse into CIGS thin films.

Carrier density measurements of the CIGS film after the hydrogen-assisted selenization process by DLCP

To certify the cell performance enhancement of surface sodium accumulation effect, DLCP is used to verify carrier density in high frequency response range³. Drive level capacitance profiling (DLCP, iHR550) is a useful technique for studying amorphous and polycrystalline semiconductors. This technique directly yields the density of states within the band gap of the semiconductor, as a function of both energy and of spatial position, requiring knowledge only of the semiconductor dielectric constant (ϵ). It also provides a much more accurate assessment of the free carrier density in the film than the C-V method⁴. As figure S5 shown, in hydrogen enhanced selenized (15% H_2) sample, the N_{DL} (drive level density) reaches as high as $3.0 \times 10^{16} \text{ cm}^{-3}$, three times larger than reference sample (0% H_2) with drive level density about $1.0 \times 10^{16} \text{ cm}^{-3}$. In previous results^{5,6}, carrier density enhancement can be thought as the merit of Na effect in CIGS film, and hydrogen enhanced selenization treatment does has the same effect.

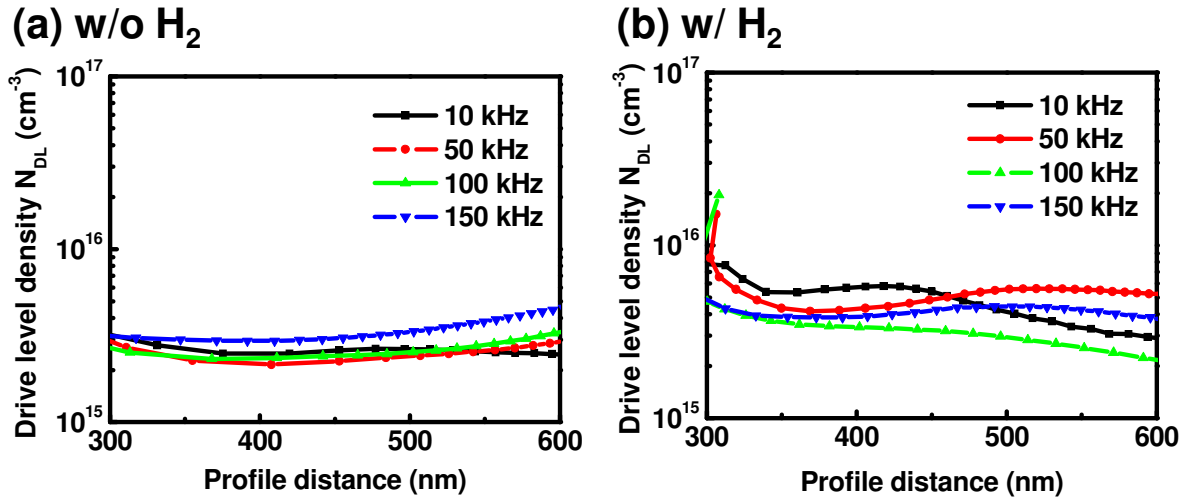
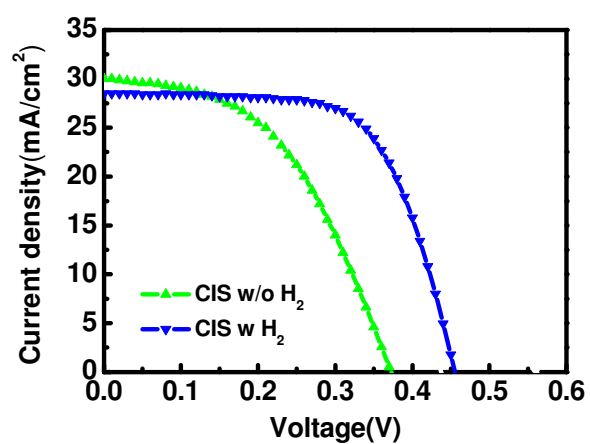


Figure S7 DLCP of carrier concentration measurement for (a) without and (b) with hydrogen-assisted Se vapor selenization. Higher drive level density ($3.0 \times 10^{16} \text{ cm}^{-3}$) represents higher carrier concentration, which is measured from the hydrogen assisted selenization sample



	Cond.	η (%)	FF	V_{oc} (mV)	J_{sc} (mA/cm ²)	R_{sh} (Ω /cm ²)	R_s (Ω /cm ²)	J_0 (A/cm ²)
CIS	w/o H ₂	5.3	48.0	370.0	30.0	60.0	3.1	7.0E-6
	w/ H ₂	8.5	64.5	460.0	28.5	849.0	1.7	1.0E-6

Figure S8 J-V measurements of CuInSe₂ solar cells after the hydrogen-assisted Se vapor selenization process.

References

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